



SiC Coated Graphite Tray

CVD process delivers extremely high purity and theoretical density of SiC coating with no porosity. With this process, Nextgen Advanced Materials supplies SiC Coated Graphite Tray with high quality and fast delivery. Customization is also available.

Product Description

Nextgen Advanced Materials INC is a professional leader SiC Coated Graphite Tray manufacturer with high quality and reasonable price. Welcome to contact us. CVD silicon carbide (SiC) coatings have lots of advantages, including ultra-high purity surfaces and extremely high wear resistance. The CVD process can provide SiC coating with extremely high purity and theoretical density without pores. Moreover, since silicon carbide is very hard, it can be polished to a mirror-like surface.

Because the coating products have excellent performance in high vacuum and high-temperature environments, Silicon Carbide Coated Graphite Trays are very suitable for the semiconductor industry and other ultra-clean environments. CVD silicon carbide coating has been applied in semiconductor industries already, such as MOCVD tray, RTP, and oxide etching chamber since silicon nitride has great thermal shock resistance and can withstand high energy plasma.





Specification	
Property	
Compound Formula	SiC
Molecular Weight	40.1
Appearance	Black

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Nextgen Advanced Materials INC www.nexgematerials.com Melting Point 2,730° C (4,946° F) (decomposes) Density 3.0 to 3.2 g/cm3 Material Graphite, with CVD SiC coating Purity >99.99% for SiC coating Surface Zero porosity Coating thickness 50~500um

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